

Fabrication of complex photonic structures with Direct Laser writing system

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Light propagation in complex photonic structures is a fascinating area of research for its fundamental implications. These kinds of materials have been widely studied to manipulate light propagation through them. Direct Laser Writing (DLW) by two-photon polymerization has emerged as a rapid, cheap and flexible fabrication method for the realization of nanostructure materials for photonics applications [1-2]. In the DLW method femtosecond pulses are tightly focused into the volume of photoresist at a frequency below the one-photon absorption threshold. The light intensity inside the focal volume exceeds the threshold for initiating the two-photon polymerization. The focus of the beam is moved in a preprogrammed pattern to fabricate the designed nanostructures.

In this work we fabricate three-dimensional photonic crystals and two-dimensional fractal structures using this technique. In particular we realize 3D-woodpile structures and we study the light propagation through them in the near-field regime as a controlled amount of disorder is introduced. The near-field characterization of the woodpile structures provides both topography and optical information of the realized structures. The far-field diffraction from the Sierpinski fractal is analyzed as the iteration number is increased.

References:

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2. M. Deubel, G. von Freymann, M. Wegener, S. Pereira, K. Busch, and C.M. Soukoulis. *Nature Mater.* **3**, 444 (2004)